



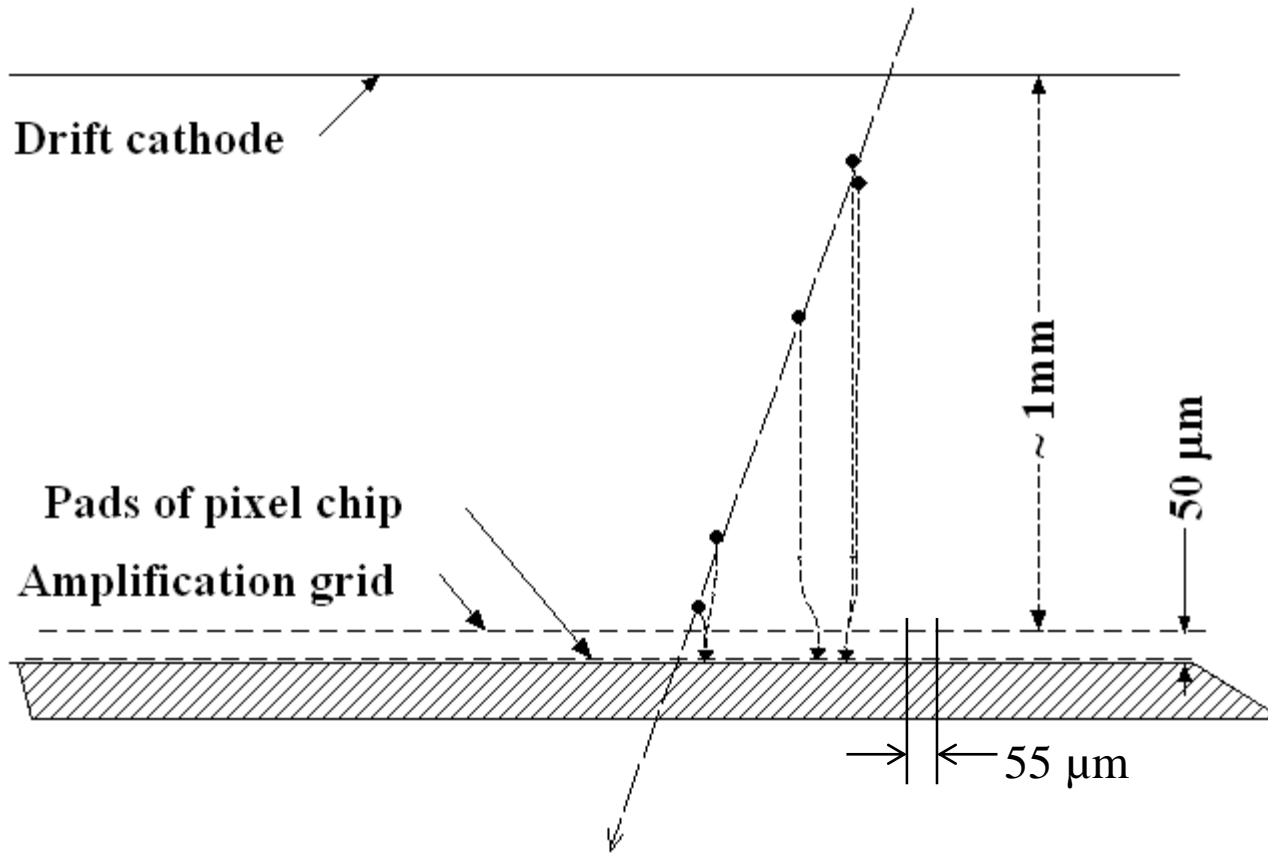
# Characterisation of protection layers in pixelised MPGDs

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RD51 miniweek, CERN  
Dec 9, 2015

# Principle GridPix detector

- ◆ Amplification grid on pixel chip
- ◆ Pixels 55  $\mu\text{m}$  pitch
- ◆ Many electrons reconstructed individually

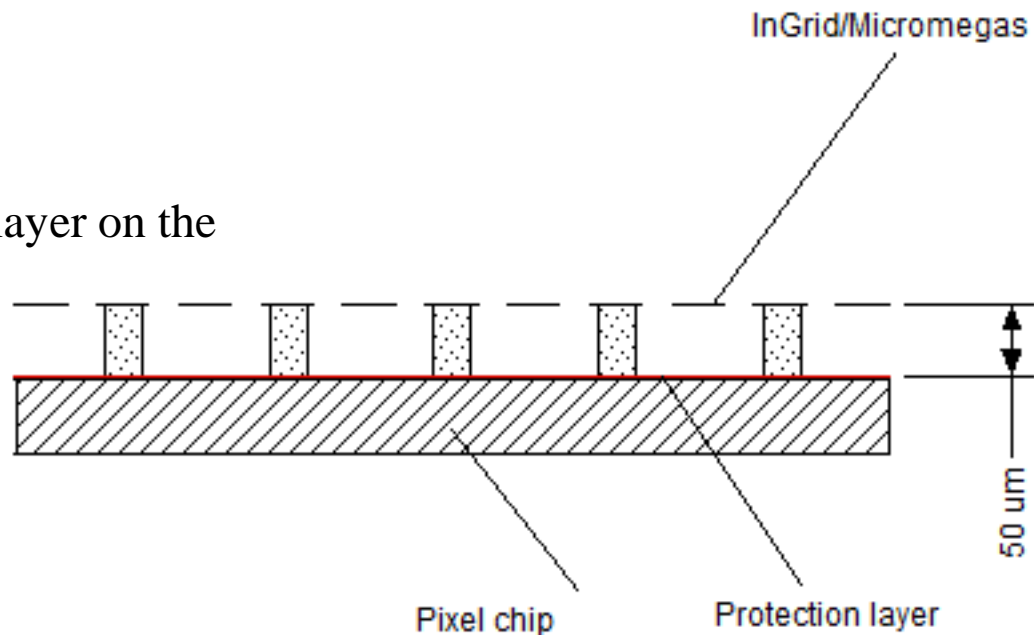


Fred Hartjes

# Protection layer in InGrid based pixel detectors

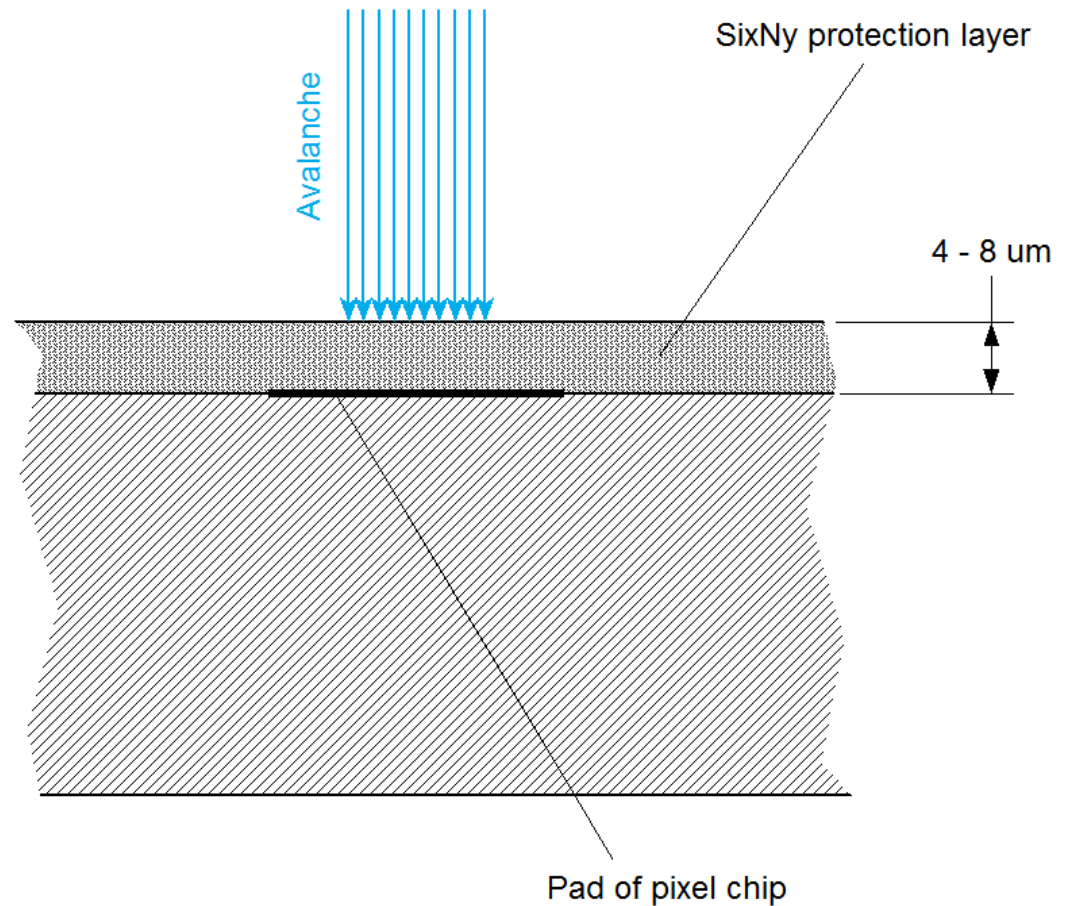
- ◆ Protection layer essential to avoid spark damage to the pixel chip
  - Raether limit  $\leq 10^8$  electrons
  - Reached for  $G = 5000$  at  $20k e^-$  primary ionization (from alfa)

- ◆ 4 – 8  $\mu m$  thick insulating layer on the anode (pads of the pixels)
  - Often resistive SixNy



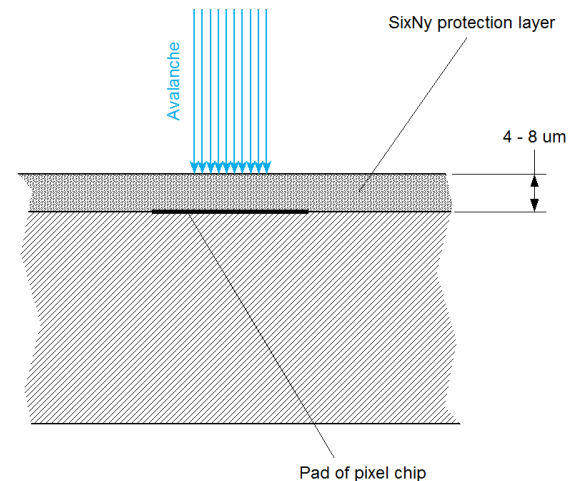
# Calculations for 4 $\mu\text{m}$ layer thickness

- ◆ For normal operation the charge signal ( $\sim 1 \text{ fC}$ ) is induced via the layer capacity ( $6.6 \text{ fF}$ ) to the pixel
- ◆ At a spark discharge ( $300 - 600 \text{ V}$ ) we induce  $\leq 2 - 4 \text{ pC}$  in the pixel input
  - No damage on electronics
  - The charge of the grid may be distributed across a  $2 \text{ mm}$  wide surface
  - But mostly the discharge is much earlier quenched
- ◆ Without protection layer we would inject  $10 - 20 \text{ nC}$  into a single pixel
  - $\Rightarrow$  fatal damage



# Requirements for the layer resistivity

- ◆ The integral of the signal currents creates voltage drop across the layer
  - Reducing the gas gain
- ◆ Maximum resistivity dependent on the particle rate and the gas gain
- ◆ Lower limit on resistivity is given by
  - Coupling fast signal to neighbouring pixels
  - Affecting the Krummenacher currents
- ◆ Example max resistivity
  - Mip rate 0.9 GHz/cm<sup>2</sup>
  - Gas gain 5000
  - 126 electron/ion pairs per track
  - Voltage drop across layer: 10 V (gain reduced by 17% for DME/CO<sub>2</sub> 50/50)
  - => **layer resistivity  $\leq 1.6 * 10^7 \Omega.m$**

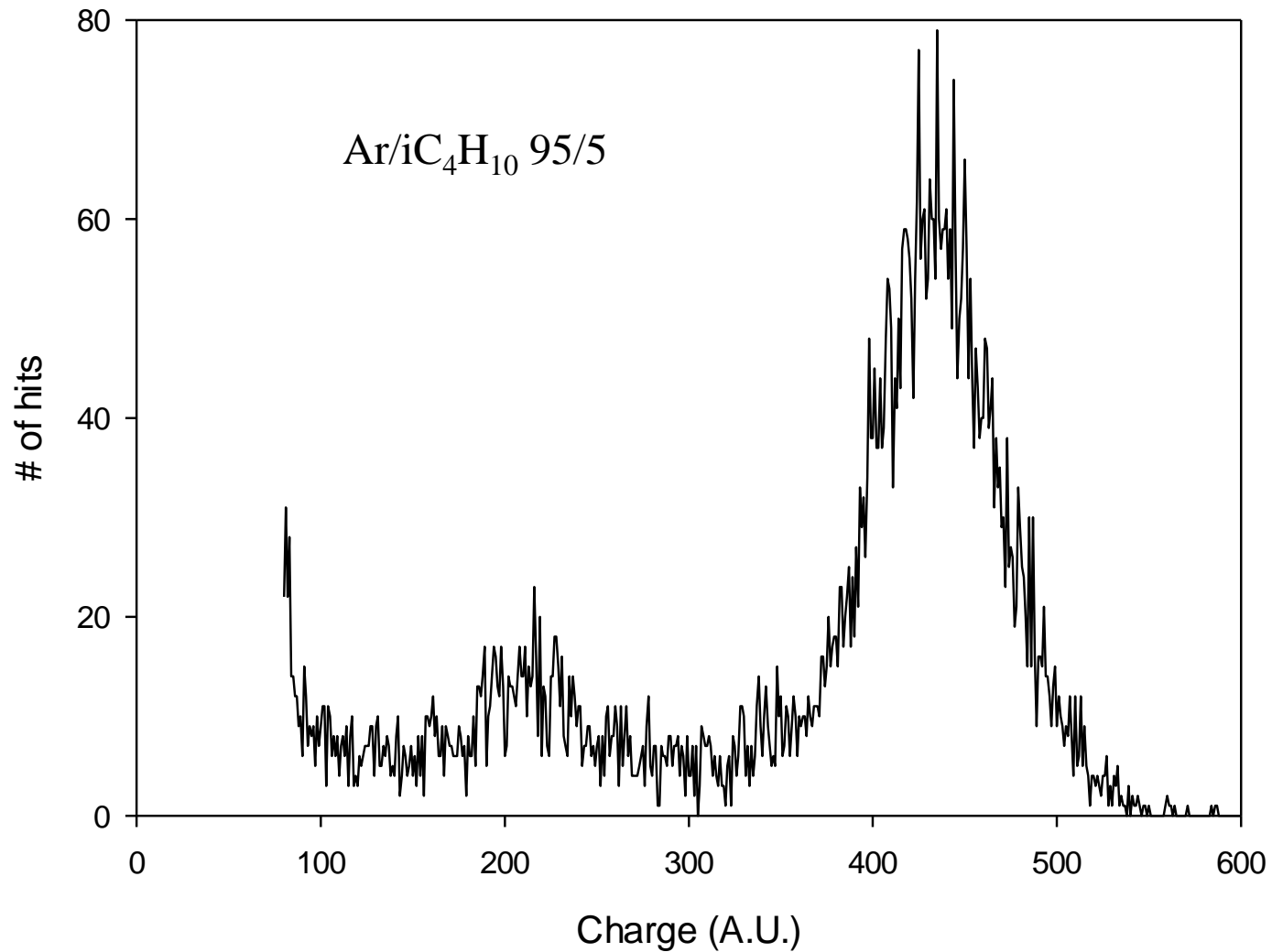


*Maybe minimum value*

# Gain measurements

# Measurements of gas gain using $^{55}\text{Fe}$ source

$^{55}\text{Fe}$  measurements



Fred Hartjes

# Example of dependence of gas gain on $V_{grid}$

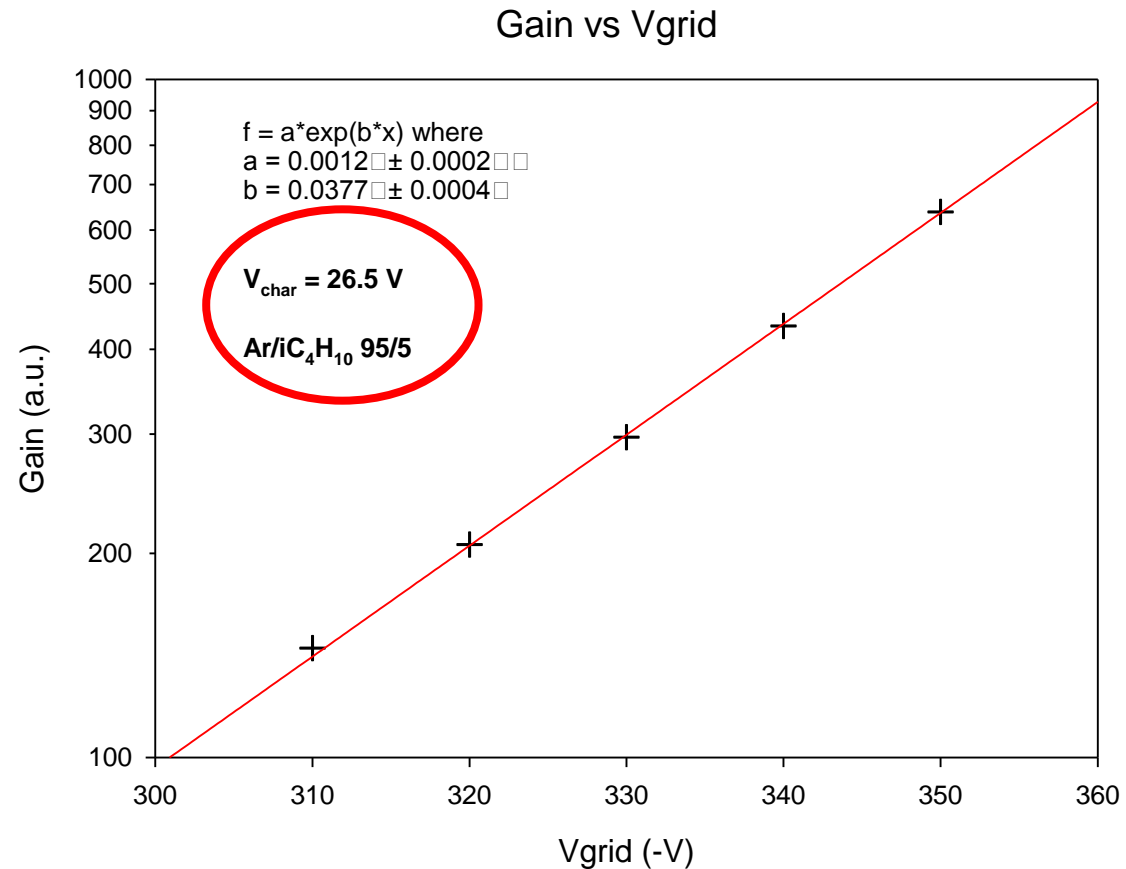
◆ Exponential growth with  $V_{grid}$

- Gain multiplied by factor **e** by increase with  $V_{char}$

$$G = A \cdot e^{\frac{V_{grid}}{V_{char}}}$$

◆ Where A is a constant

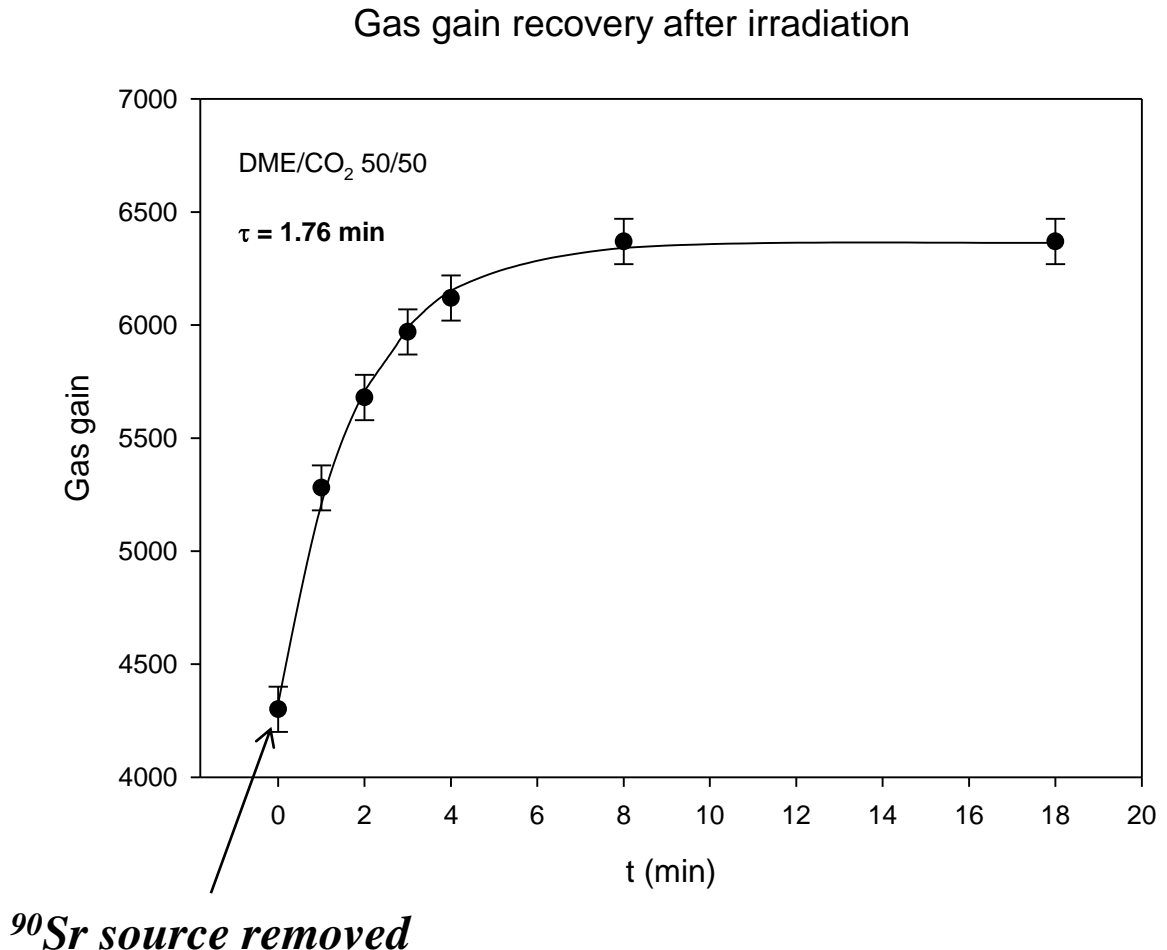
◆  $V_{char}$  dependent on type of gas, width of amplification gap etc





# Measurement of gain reduction by high irradiation rate

- ◆ TimePix3 based GridPix detector under irradiation by 5 MBq  $^{90}\text{Sr}$  on 4 cm distance
  - Gas: DME/CO<sub>2</sub> 50/50
  - Grid voltage: -610 V
- ◆ Gain considerably decreased because of voltage drop across the protection layer
- ◆ Plot shows gain recovery after removal source



# Expressions

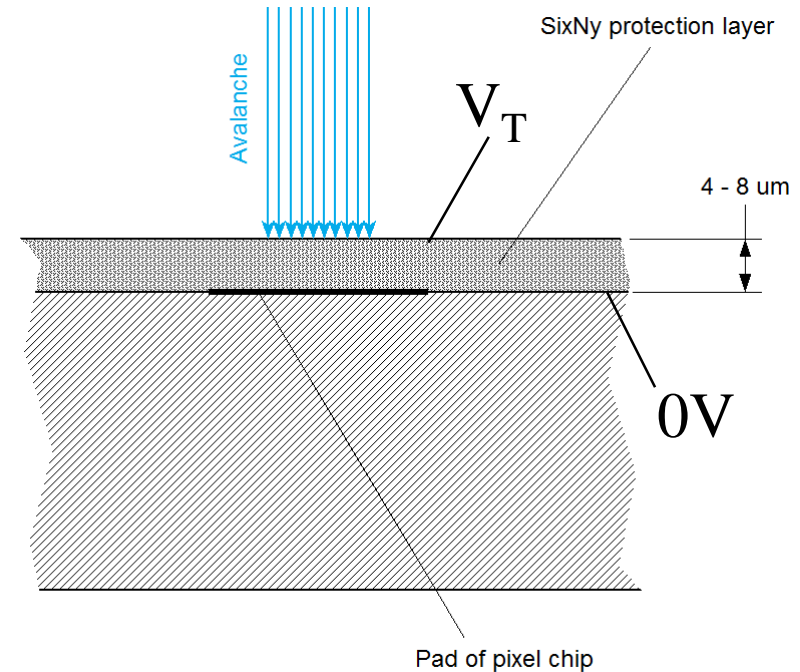
- ◆ Potential  $V_T$  is formed across the protection layer due to irradiation
- ◆ Gain  $G$  is reduced according to

$$G = G_u e^{-\frac{V_T}{V_{char}}}$$

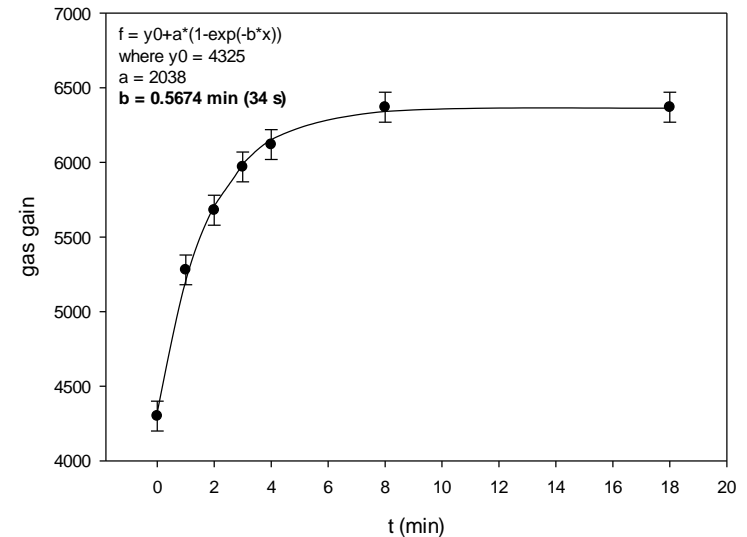
- ◆ But after removal of the source  $V_T$  falls back to zero with time  $t$

$$V_T(t) = V_{T0} e^{-t/RC}$$

- ◆ Where  $V_{T0}$  is the original potential and  $RC$  is the capacity and resistance of the investigated layer surface



Gas gain recovery after irradiation



# The volume resistance of the layer

- ◆ The RC constant of the layer is independent of the geometry of the investigated layer surface and thickness and can be written as

$$RC = \varepsilon_0 \cdot \varepsilon_r \cdot \rho$$

- ◆ Where  $\rho$  is the **volume resistance** of the layer.
- ◆ Consequently we get for the time dependent expression of the gain after removal of the source

$$G(t) = G_u e^{-\frac{V_{T0} e^{-t/\varepsilon_0 \cdot \varepsilon_r \cdot \rho}}{V_{char}}}$$

- ◆ By fitting the double exponential expression to the measured curve, the volume resistance  $\rho$  can be determined from the time dependent behaviour

# Deducing the value for $\rho$

- ◆ One may deduce  $\rho$  directly from the curve fit through the measured  $G(t)$  values

$$G(t) = G_u e^{-\frac{V_{T0} e^{-t/\varepsilon_0 \cdot \varepsilon_r \cdot \rho}}{V_{char}}}$$

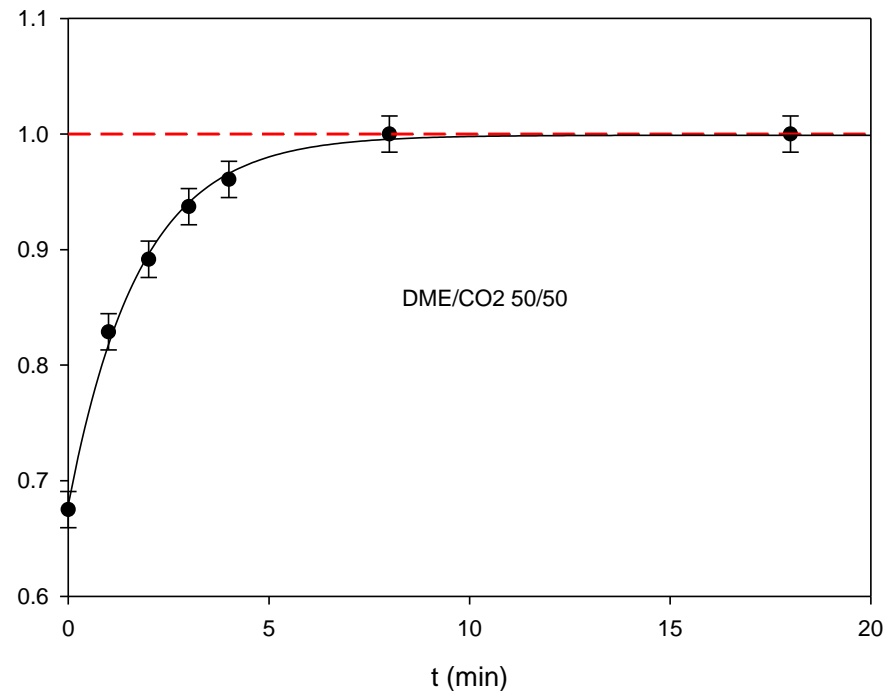
- ◆ But it is practical to convert  $G(t)/G_u$  to the corresponding  $V_T(t)$

$$V_T(t) = -V_{char} \cdot \ln \left( \frac{G(t)}{G_u} \right)$$

- ◆ Subsequently fit an exponential through the  $V_T(t)$  points

$$V_T(t) = V_{T0} e^{-t/\varepsilon_0 \cdot \varepsilon_r \cdot \rho}$$

Example of the gas gain recovery after irradiation



# Decay of the calculated voltage drop across the protection layer

◆ For the example we get

- $\epsilon_0 * \epsilon_r * \rho = 1.7 \text{ min}$
- $V_{\text{char}}$  estimated at 65V

◆ For  $\rho$  we get accordingly:

- $\rho = 1.5 * 10^{12} \text{ } \Omega\text{m}$

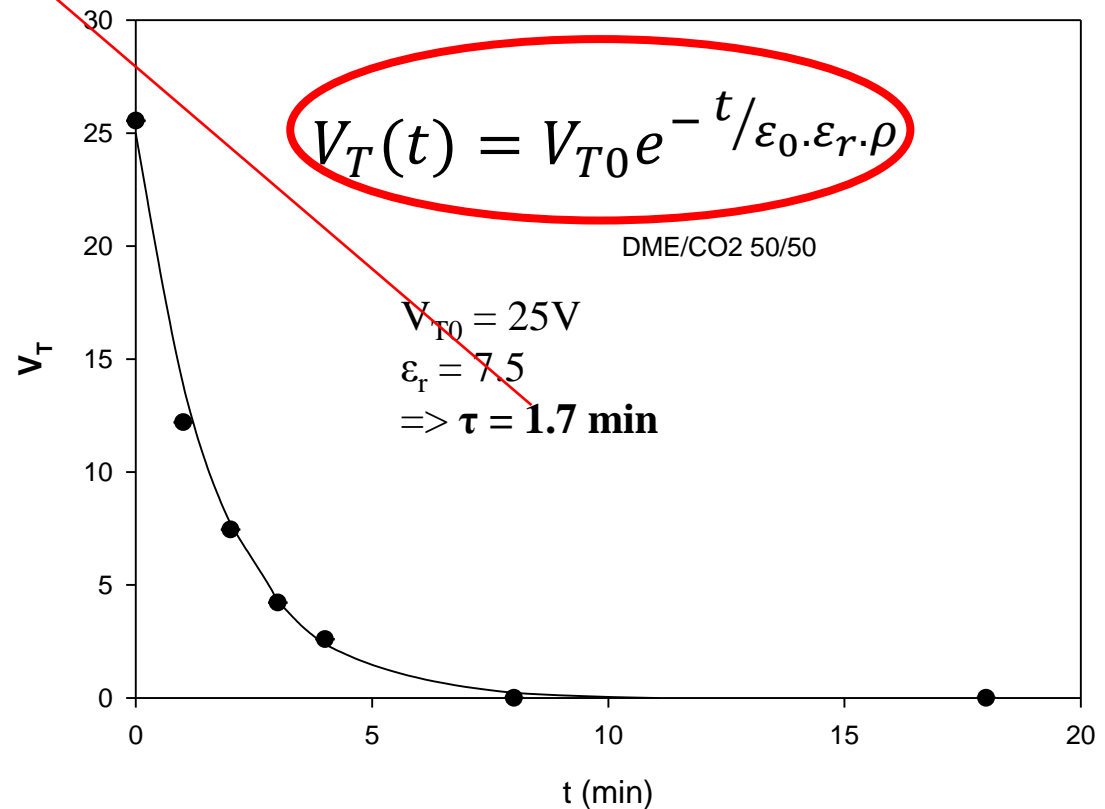
◆ The range in which  $\rho$  can be measured extends due to practical constraints from

- $10^{11} \text{ to } 10^{17} \text{ } \Omega\text{m}$
- $(10^{13} \text{ to } 10^{19} \text{ } \Omega\text{cm})$
- $(\tau = 10 \text{ s to } 117 \text{ days})$

◆ *Note: a simple exponential fit through the original  $G(t)/G_u$  curve gives about the same result*

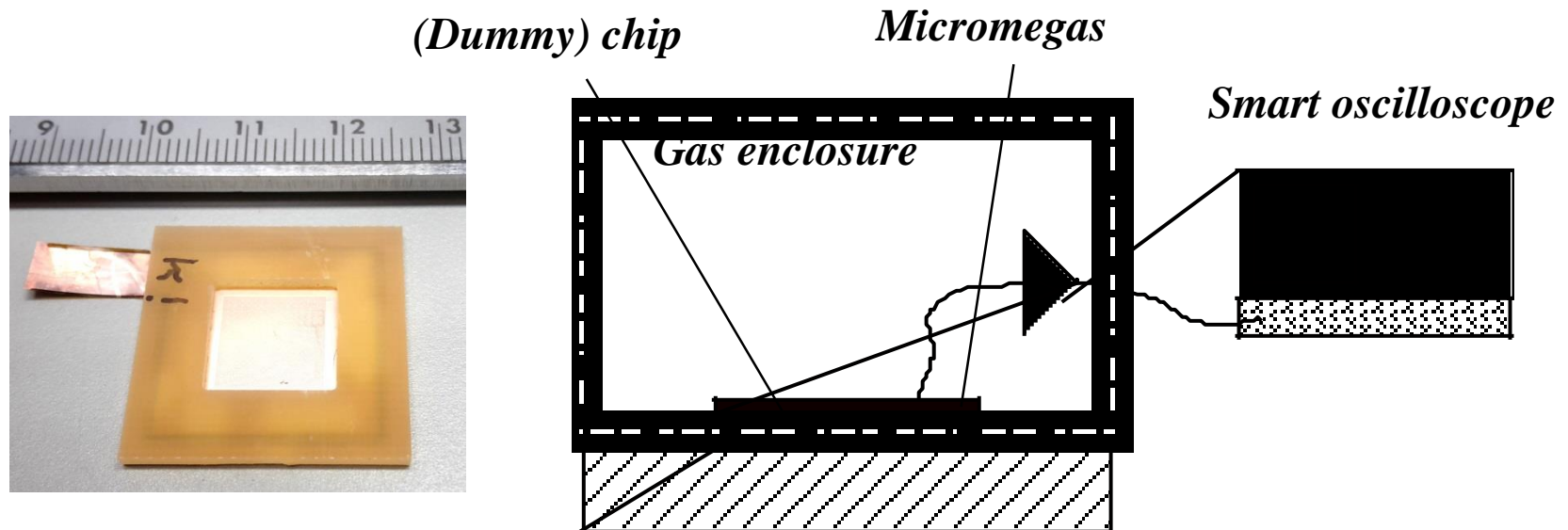
- ◆  $\tau = 1.76 \text{ min}$

Decay  $V_T$  after removal source (example)



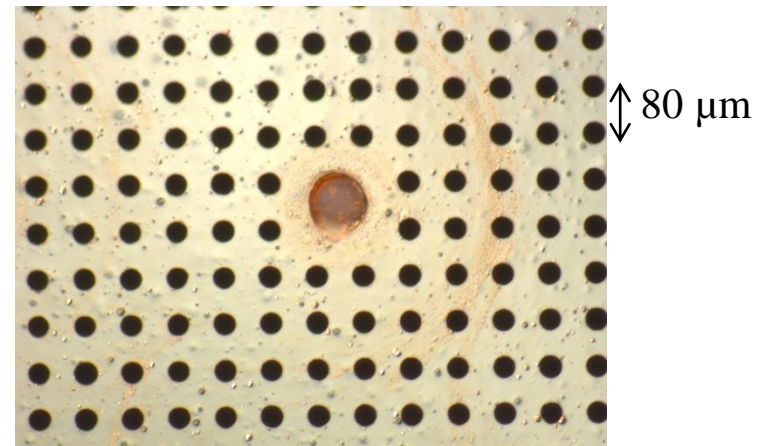
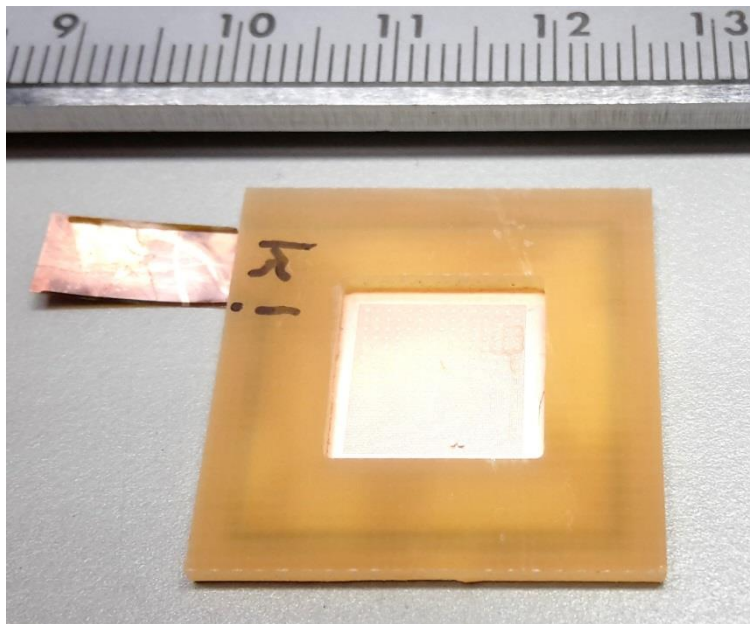
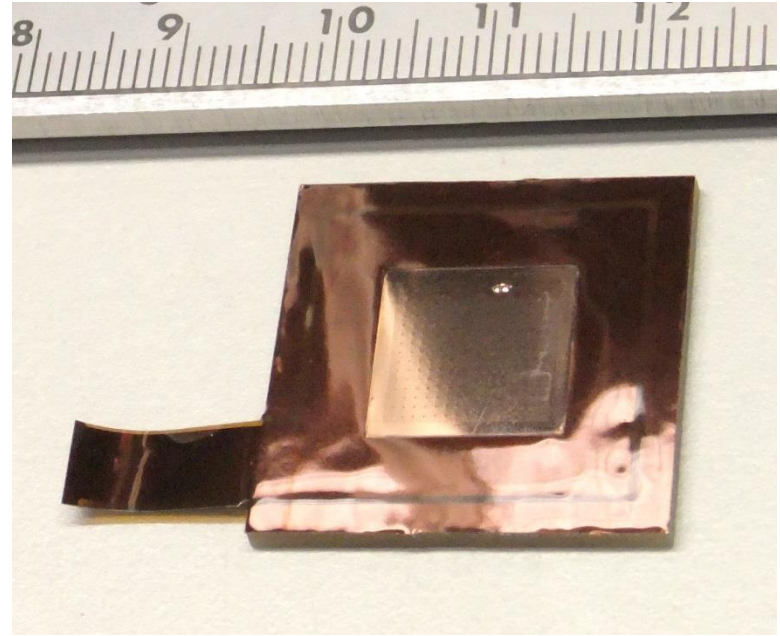
# Method to do the $\rho$ measurement of a protection layer?

- ◆ No pixel chip is needed
  - can be done well with a dummy piece of silicon
- ◆ Just place a dedicated Micromegas on top and put it in gas enclosure
- ◆ Analyse the induced signals from the Micromegas grid created by the  $^{55}\text{Fe}$  source



# Dedicated Micromegas board

- ◆ Designed by Harry van der Graaf
- ◆ 5  $\mu\text{m}$  copper on 50  $\mu\text{m}$  Kapton
- ◆ 80  $\mu\text{m}$  hole pitch
- ◆ Mounted on glass fibre epoxy frame
  - 25 x 25 mm
- ◆ Fabricated at CERN (Rui De Oliveira)



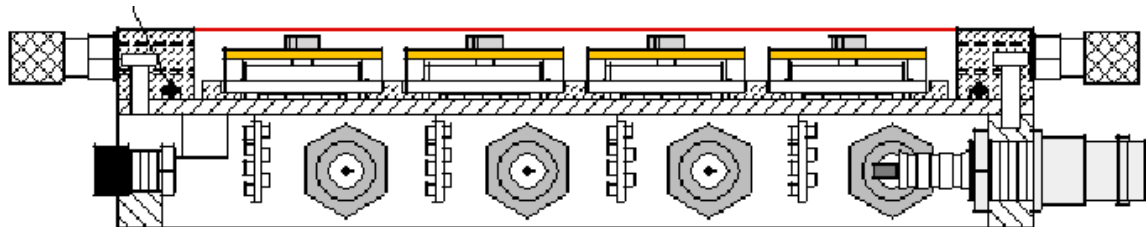
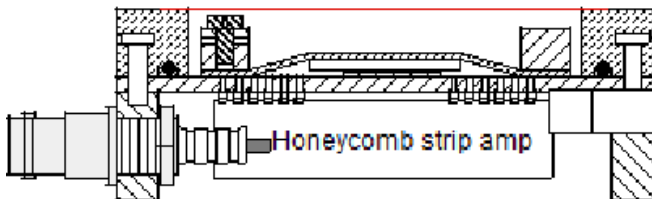
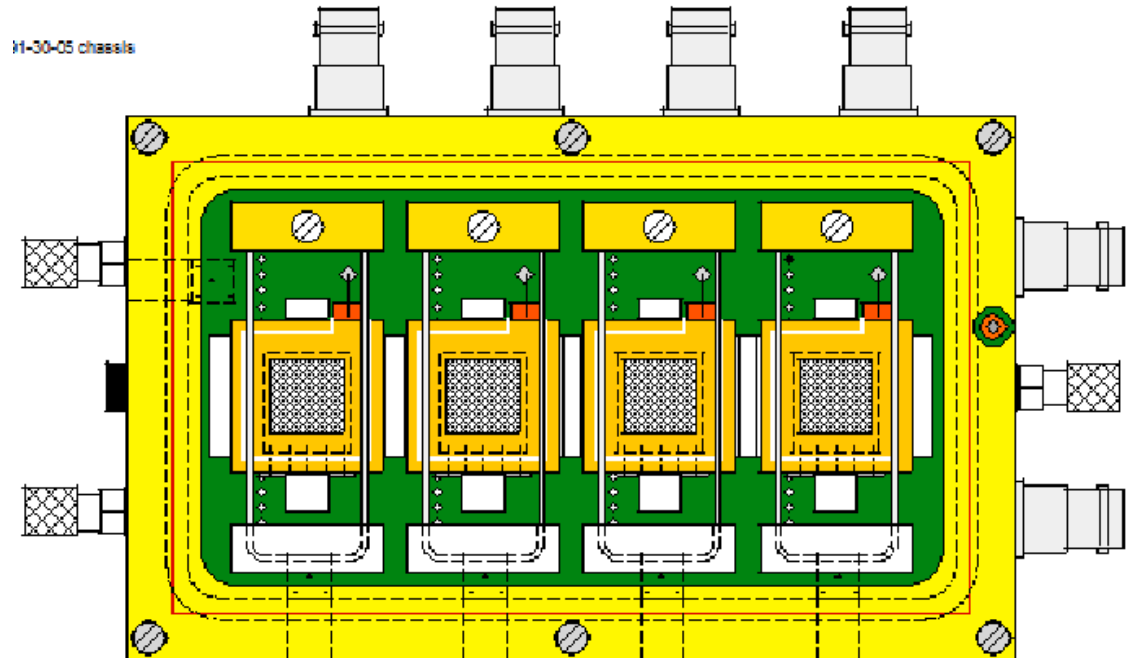
# Protection layer test device

- ◆ Designed to measure systematically the long term HV tolerance of protection layers

- Resistivity
- Breakdown sensitivity under harsh conditions

- ◆ 4 channels

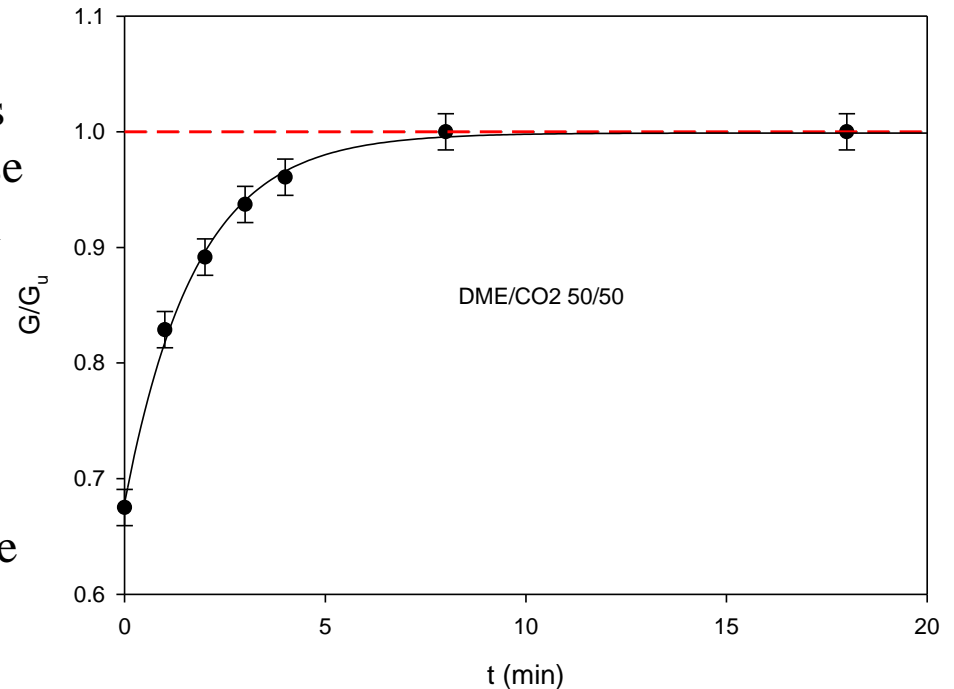
- HV from Nikhef miniHV
- nA resolution
- Good detection of sparks





# Summary

Example of the gas gain recovery after irradiation



- ◆ A pixelized gaseous detector needs a protection layer on the anode to avoid spark damage
- ◆ But the detector may experience loss of gain at high counting rates because of voltage drop across the protection layer
- ◆ This effect can be reduced by lowering the resistivity of the layer
- ◆ We devised a method where from the dynamic response of the gain to external irradiation the volume resistance can be accurately deduced between  $10^{11}$  and  $10^{17} \Omega\text{m}$
- ◆ Can also be applied for all kinds of layers on a dummy substrate
  - Interesting for MEMS technology

